

PRODUCT/PROCESS CHANGE NOTIFICATION

PCN IPD-DIS/13/7761 Dated 23 Apr 2013

DIACs in DO-35 and MiniMELF packages

Qualification of TiAl metallization

Table 1. Change Implementation Schedule

Forecasted implementation date for change	16-Apr-2013
Forecasted availability date of samples for customer	16-Apr-2013
Forecasted date for STMicroelectronics change Qualification Plan results availability	16-Apr-2013
Estimated date of changed product first shipment	23-Jul-2013

Table 2. Change Identification

Product Identification (Product Family/Commercial Product)	DIACs in DO-35 and MiniMELF packages
Type of change	Waferfab material change
Reason for change	To improve the adherence of the layers and the internal contact interface
Description of the change	The metallization of the dice used in ST DIAC devices will be modified from Ti/Ag 3 um thickness to Ti/Al 6 um thickness.
Change Product Identification	internal part number, QA number
Manufacturing Location(s)	

Table 3. L	ist of	Attachme	ents
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Customer Part numbers list	
Qualification Plan results	

PCN IPD-DIS/13/7761
Dated 23 Apr 2013
Name:
Title:
Company:
Date:
Signature:

47/.

DOCUMENT APPROVAL

Name	Function	
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Duclos, Franck	Product Manager	
Cazaubon, Guy	Q.A. Manager	

A7/.



(1) IPD: Industrial & Power Discretes - ASD: Application Specific Device - IPAD™: Integrated Passive and Active Devices

PCN Product/Process Change Notification

DIACs in DO-35 and MiniMELF packages: Qualification of TiAl metallization

Notification number:	IPD-DIS/12/7761	Issue Date	March 2013
Issued by	Aline AUGIS		
Product series affected by	the change	DB3xxx DB4xxx TMMDB3xxx	
Type of change		Wafer fab material change	

Description of the change

The **metallization** of the dice used in ST **DIAC devices** will be modified from Ti/Ag 3 μ m thickness to **Ti/Al** 6 μ m thickness.

Reason for change

ST has decided to upgrade the metalization of its Triacs devices housed in Diac package to improve the connection between the die and the metal lead of the products resulting in an optimization of the production process.

.	
	The changed products do not present modified electrical, dimensional or thermal parameters, leaving unchanged the
	current information published in the product datasheet
	The footprint recommended by ST remain the same.
	There is no change in the packing modes and the standard
	delivery quantities either.

The products remain in full compliance with the ST ECOPACK®2 grade ("halogen-free").

The new Ti/Al metallization is compliant with ST's standards.

Disposition of former products

Former versus changed product:

Deliveries of current product version will continue while the conversion is brought to completion and as long as former product stocks last.

Marking and traceability

The product marking remains unchanged.

The traceability of all products using the new metallization is ensured by the **internal part number** printed on the box labelling and by the **Q.A. number**.

Qualification complete date	March 2013
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Issue date 15-04-2013 1/2

STMicroelectronics IPD - ASD & IPAD™ Division¹ BU Thyristors/Triacs and Rectifiers



(1) IPD: Industrial & Power Discretes - ASD: Application Specific Device – IPAD™: Integrated Passive and Active Devices

Forecasted sample availability

Product family	Sub-family	Commercial part Number	Availability date
Diac	DO-35	DB3	now
Diac	DO-35	DB3TG	Week 22-2013
Diac	DO-35	DB4	Week 22-2013
Diac	Mini Melf	TMMDB3	now

All other devices will be available 4 weeks after the request.

Change implementation schedule

Sales types	Estimated production start (Front-End)	Estimated first shipments
All	Week 18-2013	Week 29-2013

Comments:

Customer's feedback

Please contact your local ST sales representative or quality contact for requests concerning this change notification.

Absence of acknowledgement of this PCN within 30 days of receipt will constitute acceptance of the change Absence of additional response within 90 days of receipt of this PCN will constitute acceptance of the change

Qualification program and results	QRP13072 Attached
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Issue date 15-04-2013 2/2



External Reliability Evaluation Report

Ti-Al metallization qualification dedicated to DIAC assembled in DO-35 and MINIMELF packages

DB3xx / DB4xx / TMMDB3

Gene	ral Information	Lo	ocations
Product Line	AC Switch	Wafer fab	ST Tours (FRANCE)
Product Description	DIAC	Assembly plant	Chinese subcontractor (9980)
Product Group	IPD	Reliability Lab	ST Tours (FRANCE)
Product division	ASD & IPAD		
Package	DO-35 and Minimelf		

DOCUMENT INFORMATION

Version Date		Pages	Prepared by	Approved by	Comment
Rev. 1	March 08, 2013	9	Gilles DUTRANNOY	Jean-Paul REBRASSE	
Rev. 2	March 26, 2013	9	Gilles DUTRANNOY		

Note: This report is a summary of the reliability trials performed in good faith by STMicroelectronics in order to evaluate the potential reliability risks during the product life using a set of defined test methods.

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1 APPLICABLE AND REFERENCE DOCUMENTS

Document reference	Short description
JESD 22	Reliability test methods for packaged devices
JESD 47	Stress-Test-Driven Qualification of Integrated Circuits
JESD 94	Application specific qualification using knowledge based test methodology
MIL-STD-750C	Test method for semiconductor devices
SOP 2614	Reliability requirements for product qualification (ST internal document)
SOP 267	Product maturity levels (ST internal document)
RER1214011	Confidential ST Internal Reliability Report

2 GLOSSARY

вом	Bill Of Materials
D-FMEA	Device-oriented Failure Mode and Effects Analysis
DUT	Device Under Test
F/G	Finished Good
HTS	High Temperature Storage
PCN	Process Change Notification
RH	Relative Humidity
RSH	Resistance to Solder Heat
SAM	Scanning Acoustic Microscopy
SMPS	Switch Mode Power Supply
SS	Sample Size
TCT	Temperature Cycling Test
ТНВ	Temperature Humidity Bias



IPD (Industrial & Power Discretes) Group ASD & IPAD division Quality and Reliability

March 26th, 2013 Report ID: 13072QRP

3 RELIABILITY EVALUATION OVERVIEW

3.1 Objectives

This project consists in the qualification of the Ti-Al metallization dedicated to DIAC dice assembled in the DO-35 and MINIMELF packages in China.

3.2 Conclusion

Qualification Plan requirements have been fulfilled without exception. Reliability tests have shown that the devices behave correctly against environmental tests (no failure). Moreover, the stability of electrical parameters during the accelerated tests demonstrates the robustness of the product which is consequently expected during their lifetime.



4 DEVICE CHARACTERISTICS

4.1 **Device descriptions**



FEATURES

- V_{BO}: 32V and 40V
- . LOW BREAKOVER CURRENT





DO-35 (DB3 and DB4)

DESCRIPTION

Functioning as a trigger diode with a fixed voltage reference, the DB3/DB4 series can be used in conjunction with triacs for simplified gate control circuits or as a starting element in fluorenscent lamp ballasts.

A new surface mount version is now available in SOT-23 package, providing reduced space and compatibility with automatic pick and place equipment.

ABSOLUTE MAXIMUM RATINGS (limiting values)

Symbol	Parameter		Value	Unit
I _{TRM}	Repetitive peak on-state current to = 20 us F= 120 Hz	SMDB3	1.00	Α
	Viii	DB3 / DB4	5	
Tstg Tj	Storage temperature range Operating junction temperature range	0.0	- 40 to + 125	чC

Note: * SMDB3 indicated as Preliminary specias product is still in development stage.



TMMDB3

FEATURES

- . VBO: 32V
- Breakover voltage range: 28 to 36V

DESCRIPTION

Functioning as a trigger diode with a fixed voltage reference, the TMMDB3 can be used in conjunction with triacs for simplified gate control circuits or as a starting element in fluorescent lamp ballasts.



MINIMELF

ABSOLUTE MAXIMUM RATINGS (limiting values)

Symbol	Parameter	Value	Unit
Іттем	Repetitive peak on-state current tp = 20 µs F= 120 Hz	2	A
Tstg T]	Storage temperature range Operating junction temperature range	- 40 to + 125	°C



5 TESTS RESULTS SUMMARY

5.1 Test vehicle

Two test vehicles were chosen:

- DB3
- TMMDB3

lot	P/N	Package	Comment	
1	DB3	DO35	Qualification lot	
2	DB3	DO35	Qualification lot	
3	TMMDB3	MINIMELF	Qualification lot	

5.2 Test plan and results summary

Test	P/N	Std ref.	Conditions	ss	Step	LOT 1	LOT 2
		Method 1032 1000 h		168 h	0/77	0/77	
HTS			154	500 h	0/77	0/77	
	DB3				1000 h	0/77	0/77
TC		JESD22 A-104	-65 °C/+150 °C 2 cycles/h	154	100 cycles	0/77	0/77
		0L0D22 A-104	500 cycles	154	500 cycles	0/77	0/77

Test	P/N	Std ref.	Conditions	ss	Step	Failure/SS
				77	168 h	0/77
нтѕ		MIL-STD-750C T _j Method 1032	T _j = 125 °C 1000 h		500 h	0/77
	TMMDB3				1000 h	0/77
тс		-65 °C/+150 °C	-65 °C/+150 °C 2 cycles/h		100 cycles	0/77
10		500 cycles		, ,	500 cycles	0/77
RSH		J-STD-002	260 °C, 15 s ON, 10 s OFF	30	2 cycles	0/30



6 ANNEXES

6.1 **Device details**

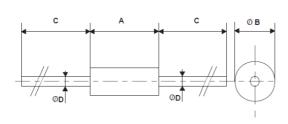
6.1.1 Pin connection





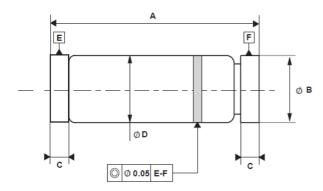
6.1.2 Package outline/Mechanical data

DO-35



REF.	DIMENSIONS					
	Millimeters		Millimeters		Inc	hes
	Min. Max.		Min.	Max.		
Α	3.05	4.50	0.120	0.177		
В	1.53 2.00		0.060	0.079		
С	28.00		1.102			
D	0.458	0.558	0.018 0.022			

MINIMELF



REF.	DIMENSIONS						
	Mi	llimete	ers		Inches		
	Min.	Тур.	Max.	Min.	Тур.	Max.	
Α	3.30	3.40	3.6	0.130	0.134	0.142	
В	1.59	1.60	1.62	0.063	0.063	0.064	
С	0.40	0.45	0.50	0.016	0.018	0.020	
D		1.50			0.059		



6.2 <u>Tests Description</u>

Test name	Description	Purpose
Die and Package-oriented test		
HTS High Temperature Storage	The device is stored in unbiased condition at the maximum temperature allowed by the package materials, sometimes higher than the maximum operating temperature.	To investigate the failure mechanisms activated by high temperature, typically wire-bonds solder joint aging, data retention faults, metal stress- voiding.
RSH Resistance to Solder Heat	The device is submitted to a dipping in a solder bath at 260 °C with a dwell time of 10 s.	This test is used to determine whether solid state devices can withstand the effects of the temperature to which they will be subjected during soldering of their leads. The heat is conducted through the leads into the device package from solder heat at the reverse side of the board. This procedure does not simulate wave soldering or reflow heat exposure on the same side of the board as the package body.
Solderability	This evaluation is made on the basis of the ability of these terminations to be wetted and to produce a suitable fillet when coated by tin lead eutectic solder. These procedures will test whether the packaging materials and processes used during the manufacturing operations process produce a component that can be successfully soldered to the next level assembly using tin lead eutectic solder. A preconditioning test is included in this test method, which degrades the termination finish to provide a guard band against marginal finish.	To provide a referee condition for the evaluation of the solderability of terminations (including leads up to 0.125 inch in diameter) that will be assembled using tin lead eutectic solder.
THB Temperature Humidity Bias	The device is biased in static configuration minimizing its internal power dissipation, and stored at controlled conditions of ambient temperature, and relative humidity.	To evaluate the package moisture resistance with electrical field applied, both electrolytic and galvanic corrosion are put in evidence.
TC Temperature Cycling	The device is submitted to cyclic temperature excursions, between a hot and a cold chamber in air atmosphere.	To investigate failure modes related to the thermo-mechanical stress induced by the different thermal expansion of the materials interacting in the die-package system. Typical failure mechanisms are linked to metal displacement, dielectric cracking, molding compound delamination, wire-bonds failure, dieattach layer degradation.



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March 26th, 2013 Report ID: 13072QRP

6.3 APPENDIX

Products involved in this qualification:

- DB3xxx
- DB4xxx
- TMMDB3xxx

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